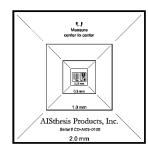
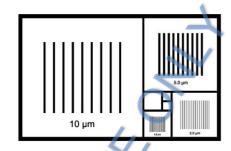






Wafer Level Certificate of Traceability for Pelcotec™ Critical Dimension Magnification Standard





Product Number: Pelcotec™ 691-1 CDMS-1T-ISO

Product Description: 2.5x2.5mm, Pelcotec™ 2mm-1µm Critical Dimension Magnification Standard

Wafer Identifier: CD-AI03

As Received Condition: New

As Returned Condition: N/A

Date of Receipt: N/A

Customer name and contact information:



P.O. Box 492477

Redding, CA 96049-2477

Tel: 530.243.2200

www.tedpella.com

The accuracy of this product with Wafer Identifier CD-Al03 was determined using a Field Emission Scanning Electron Microscope (FE-SEM) by reference comparison to working standards traceable to the National Institute of Standards and Technology (NIST), using CP 01 FE-SEM Imaging of Critical Dimension Magnification Standards (CDMS) and CP 02 Certification of Critical Dimension Magnification Standards. Die were sampled according to method SOP 08 Sampling Die. The data applies only to the CDMS products identified in this report. All results are "as-is". Repair and/or adjustments are not possible.

Below are the average ISO 17025:2017-compliant Certified 10 µm Pitch Measurements unique to Die with Wafer Identifier CD-AI03 and traceable to NIST Certified Standard CD-PG01-0211.

| Line | ISO 17025:2017 Compliant Certified Average Pitch | Position of Measurement |
|----------|---|-------------------------|
| 0-10 μm | on Wafer 9.998 μm | ± 7.5 µm from center |
| 10-20 µm | 10.000 µm | ± 7.5 µm from center |
| 20-30 μm | 10.003 µm | ± 7.5 µm from center |
| 30-40 μm | 10.000 µm | ± 7.5 µm from center |
| 40-50 μm | 10.002 μm | ± 7.5 µm from center |
| 50-60 µm | 9.999 µm | ± 7.5 µm from center |
| 60-70 μm | 10.000 µm | ± 7.5 µm from center |

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| | 70-60 μπ | 9.996 µm | ± 7.5 µm nom center |
|---|----------|-----------|---------------------|
| | | | |
| _ | | | • |
| | Average | 10 000 um | |

| Average | 10.000 μm |
|-----------|-----------|
| 2-Sigma * | 0.0331 µm |

^{*} Corrected for sample size using the appropriate Student t-factor.

Measurements are reported with an uncertainty (k=2)** of \pm 0.012 μ m. Statements of Conformity are not provided in this report. Review the results and verify that they meet the requirements for the intended use. Physical damage to or contamination of the CDMS occurring after calibration may invalidate the reported measurements. Use this product at 25°C \pm 5°C and at less than 80% RH.

^{**} Reported uncertainties represent expanded uncertainties expressed at approximately the 95% confidence level using a coverage factor of k = 2. The reported expanded measurement uncertainty is stated as the standard measurement uncertainty multiplied by the coverage factor K such that the coverage probability corresponds to approximately 95%.

| Line | Number of Lines | Position of Measurement Compliant Average Measured Distance (first to last line) | | Average Pitch |
|---------|-----------------|--|-------------------|---------------|
| 2.0 mm | 2 | ± 1.00mm from center | 2.00 mm | 2.00 mm |
| 1.0 mm | 2 | ± 0.5mm from center | 1.00 mm | 1.00 mm |
| 0.5 mm | 2 | ± 0.25mm from center | 0.500 mm | 0.500 mm |
| 0.25 mm | 2 | ± 0.125mm from center | 0.250 mm | 0.250 mm |
| 10 µm | 9 | ± 7.5 µm from center | 4 80.00 μm | 10.00 µm |
| 5.0 µm | 12 | ± 20 µm from center | 55.01 μm | 5.00 µm |
| 2.0 µm | 16 | ± 10 µm from center 🥕 | 30.04 μm | 2.00 µm |
| 1.0 µm | 17 | ± 5 µm from center | 16.02 μm | 1.00 µm |

The average pitch is derived from the stated length that was determined using measurements (taken center-to-center) over the stated number of lines (i.e., length divided by the number of lines minus one).

Date of Analysis: January 29th, 2023

Equipment used:

| Instrument | Model | Serial # | Resolution | Repeatability | Temperature | Humidity | Ref. |
|------------|------------|----------|------------|---------------|---------------|----------|----------|
| FE-SEM | FEI Verios | 9922551 | 0.9nm | 0.030% | 23.3 ± 0.3 °C | 42.5 ± | CD-PG01- |
| | 460L | | | | | 1.5% | 0211 |

Location: Analytical Instrumentation Facility, NC State University, Raleigh NC 27695-7531.

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|---|------|--|
| | | |

| D.S. Finch Certified by | _ Signature | 4 |
|----------------------------|----------------|---------------------------------------|
| H. Haehlen | <u> </u> | <u>January 29th, 2023_</u> |
| Authorized by | Signature | Date report issued. |

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End of report.

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